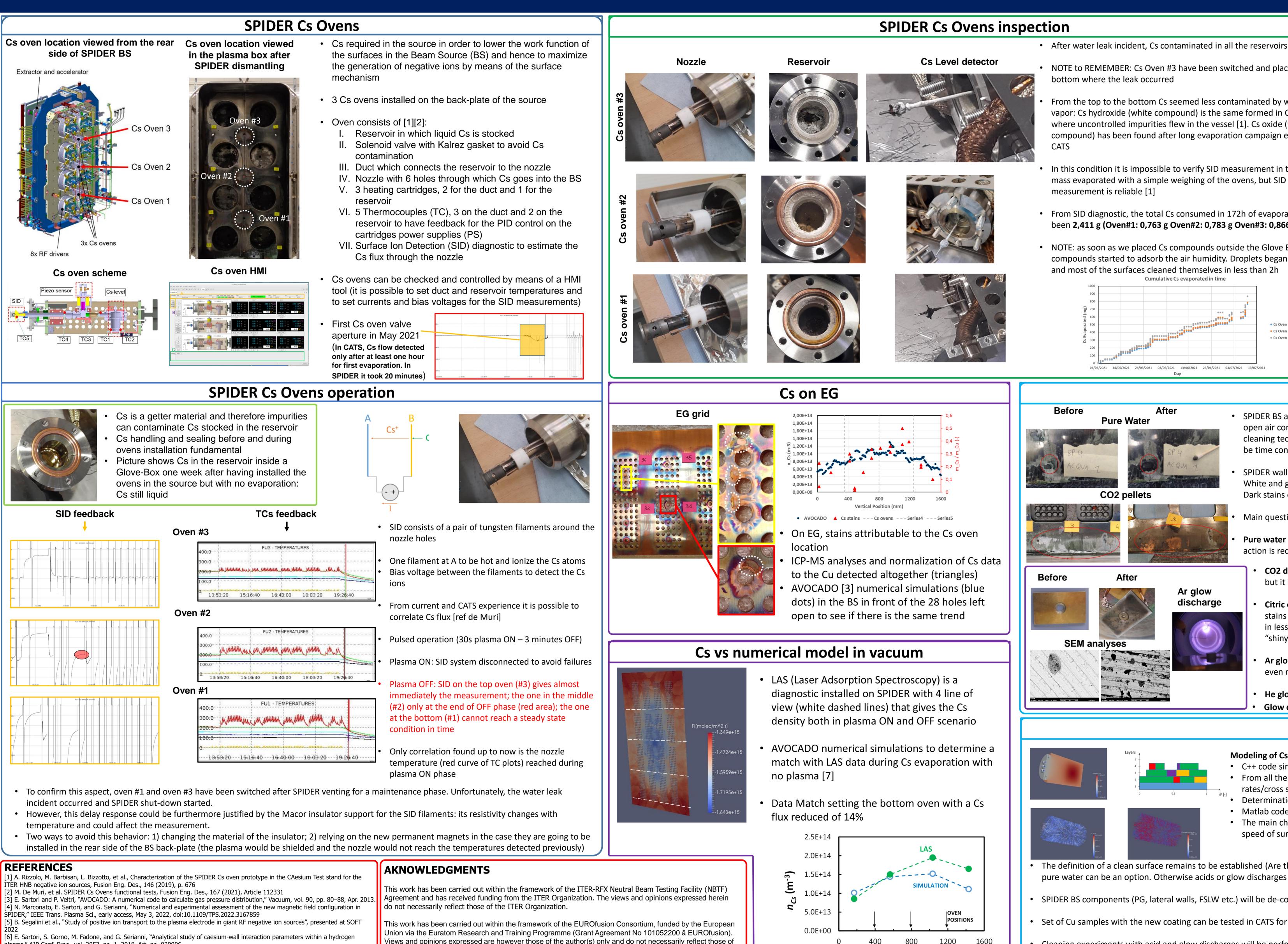




Summary of caesium evaporation and deposition during SPIDER first campaign



plasma," AIP Conf. Proc., vol. 2052, no. 1, 2018, Art. no. 020006, [7] M. Fadone, M. Barbisan, S. Cristofaro, M. De Muri, G. Serianni, E. Sartori, Interpreting the dynamic equilibrium during evaporation in a cesium environment, Rev. Sci. Instrum., 91 (1) (2020)

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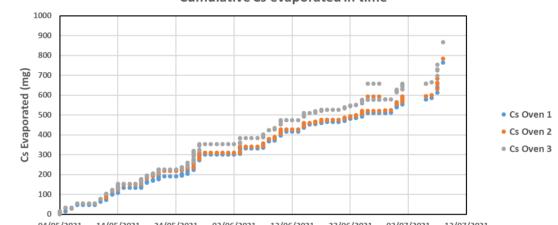
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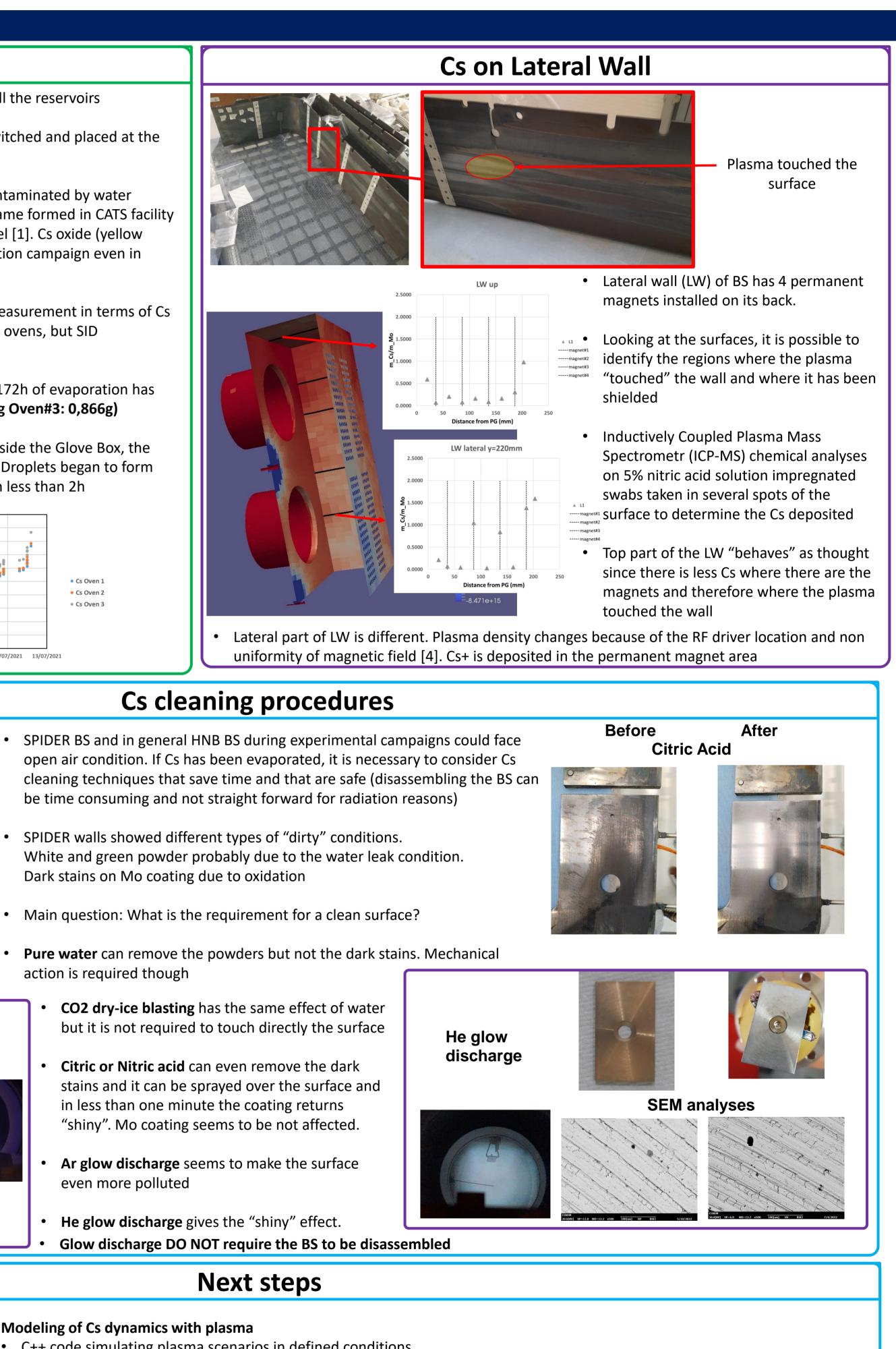


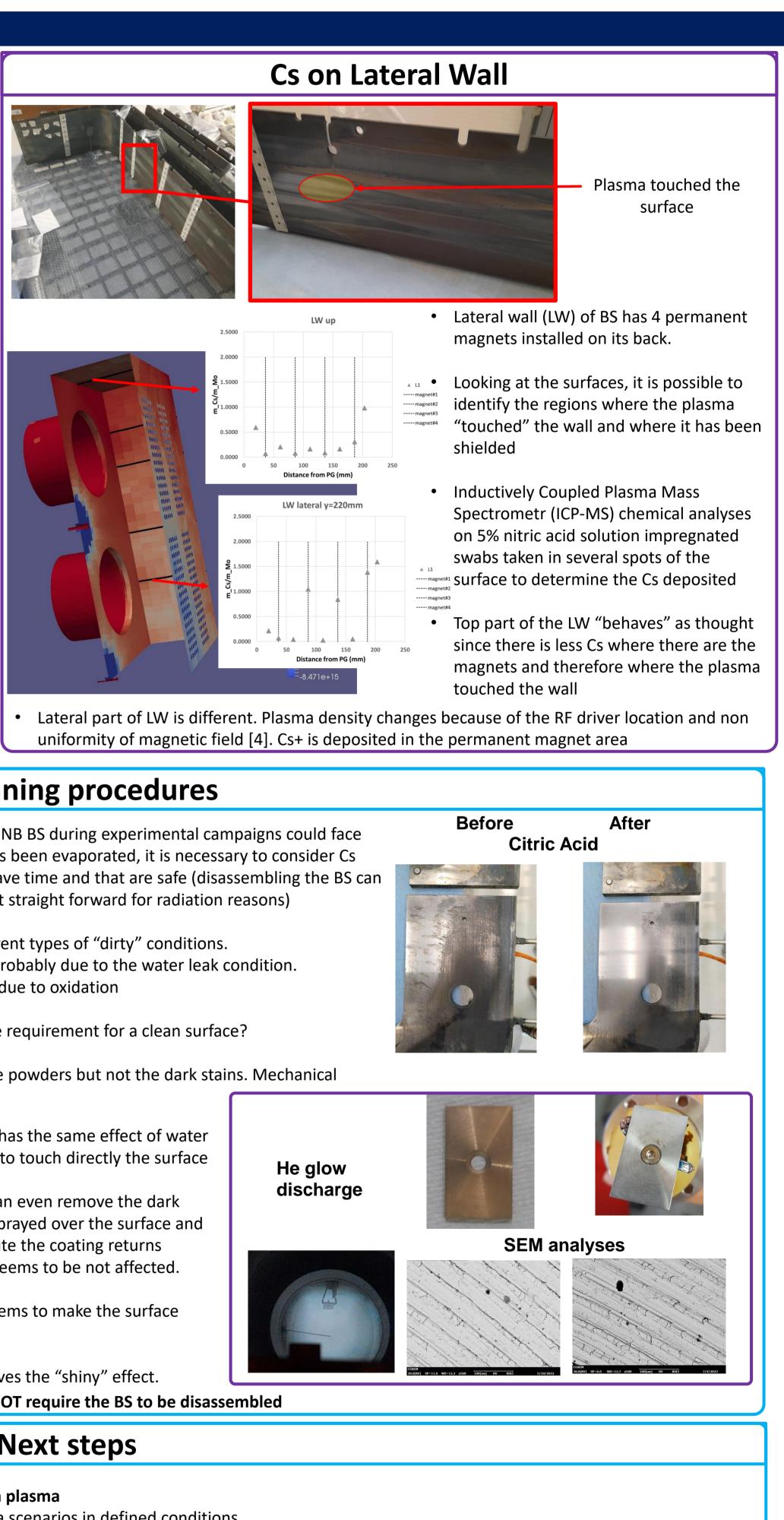


y (mm)

- NOTE to REMEMBER: Cs Oven #3 have been switched and placed at the
- bottom where the leak occurred From the top to the bottom Cs seemed less contaminated by water
- vapor: Cs hydroxide (white compound) is the same formed in CATS facility where uncontrolled impurities flew in the vessel [1]. Cs oxide (yellow compound) has been found after long evaporation campaign even in CATS
- In this condition it is impossible to verify SID measurement in terms of Cs mass evaporated with a simple weighing of the ovens, but SID measurement is reliable [1]
- From SID diagnostic, the total Cs consumed in 172h of evaporation has been 2,411 g (Oven#1: 0,763 g Oven#2: 0,783 g Oven#3: 0,866g)
- NOTE: as soon as we placed Cs compounds outside the Glove Box, the compounds started to adsorb the air humidity. Droplets began to form and most of the surfaces cleaned themselves in less than 2h Cumulative Cs evaporated in time







Before After **Pure Water** be time consuming and not straight forward for radiation reasons) SPIDER walls showed different types of "dirty" conditions. White and green powder probably due to the water leak condition. CO2 pellets Dark stains on Mo coating due to oxidation Main question: What is the requirement for a clean surface? action is required though **CO2 dry-ice blasting** has the same effect of water Before After but it is not required to touch directly the surface Ar glow discharge **Citric or Nitric acid** can even remove the dark stains and it can be sprayed over the surface and in less than one minute the coating returns "shiny". Mo coating seems to be not affected. SEM analyses Ar glow discharge seems to make the surface even more polluted the the second A THE REAL PROPERTY. He glow discharge gives the "shiny" effect Modeling of Cs dynamics with plasma • C++ code simulating plasma scenarios in defined conditions rates/cross sections available (also Cs excitation is considered in analogy to [5]) • Determination of matrices of view-factors as outputs for the final stage Matlab code to consider layer Cs depositon/release considering also impurities [6] speed of surface formation Further chemical analyses • The definition of a clean surface remains to be established (Are the dark stains a problem? Do we want the surfaces to be perfectly shiny?). If dark stains are ok, then CO2 pellets or pure water can be an option. Otherwise acids or glow discharges should be used SPIDER BS components (PG, lateral walls, FSLW etc.) will be de-coated and re-coated with a new molybdenum coating Set of Cu samples with the new coating can be tested in CATS for Cs deposition 1200 1600 Cleaning experiments with acid and glow discharges will be performed on the samples to have a more reliable comparison with the future SPIDER scenarios (SEM quantitative



• From all the surfaces, Cs neutrals and ions are "launched" in order to determine the trajectories considering all the collision

• The main challenge is to understand which chemical process is most important and how to quantify the conditions and the

analyses will be performed on the exact same sample locations to have a proper quantitative comparison)